EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S28	322	257/725.ccls. and (@ad<"20031030" or @rlad<"20031030")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:04
S29	3549	(257/758).ccls. and (@ad<"20031030" or @rlad<"20031030")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:04
S30	265	(257/758).ccls. and (@ad<"20031030" or @rlad<"20031030") and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:05
S31	128	(257/773).ccls. and (@ad<"20031030" or @rlad<"20031030") and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:06
S32	224	(257/773,786).ccls. and (@ad<"20031030" or @rlad<"20031030") and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:15
S33	132	(438/669,926).ccls. and (@ad<"20031030" or @rlad<"20031030") and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:22
S34	194	(257/E23.151,E23.175).ccls. and (@ad<"20031030" or @rlad<"20031030") and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/27 20:23
S35	1156	semiconductor and (wiring or conductor or electrode) and @ad<"20031030" and (dummy with (pattern$3 or structure or layer or wiring)) and (CMP or polish$4 or damascene) and (cvd or vapor adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/28 00:07